Carbonate formation lowers the electrocatalytic activity of perovskite oxides for water electrolysis

SUPPLEMENTARY INFORMATION

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Supplementary Figure 1: (a) RHEED pattern after growth. (b) Atomic force microscopy after UHV-transfer to the AFM chamber. (c) RHEED pattern after electrochemical characterization. The intensity of the electron beam was identical and all settings as similar to panel a as possible. The loss in intensity of the diffraction spots compared to the background intensity indicates a slight loss of surface crystallinity. (d) Atomic force microscopy after electrochemical characterization.



Supplementary Figure 2: (a) Cyclic voltammetry of a 50 nm Pt layer at 500 mV/s. The redox features are labeled according to Bard and Faulkner.¹⁹ H_c/H_a: formation/oxidation of adsorbed hydrogen. O_a/O_c: formation/reduction of adsorbed oxygen or a platinum oxide layer. (b) Pt 4*f* XPS after deposition and after potential holds at different potentials as indicated in panel a. First, the film was oxidized at 1.88 V vs. RHE, then it was reduced at -0.11 V vs. RHE, followed by reoxidation at 1.08 and 1.38 V vs. RHE, respectively. (c) representative XPS fitting of the Pt 4*f* level. (d) Relative intensity of the Pt oxide peaks as a function of applied potential.



Supplementary Figure 4: (a) Cyclic voltammetry of the same films as in Figure 2 of the main text and current normalization: The current ratio was obtained by dividing the data from the air-exposed sample by the clean-transfer data. The ratio is fairly constant at \sim 70 to 80 %.



Supplementary Figure 3: (a) O1s spectrum of a LaNiO₃ film in O₂ at 300 °C. The surface is clean except for a small contamination peak often observed for perovskite oxides (doi/10.1021/acs.chemmater.9b05151) (b) Top panel: Increase of the peak corresponding to the O $1s^{CO_3}$ and contaminations during cooling down in CO₂. Based on their binding energy, these peaks could not be separated unambiguously. Middle and bottom panel: Intensity ratio of the C $1s^{CO_3}$ peak and the total Ni 3p intensity (same data as shown in Fig. 5 of the main text). (c) O1s spectrum of the same film after cooling down to room temperature in CO₂.